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PTO/SB/21 (09-04) Approved for use through 07/31/2006. OMB 0651-0031
U.S. Patent and Trademark Office; U.S. DEPARTMENT OF COMMERCE
Inder the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it displays a valid OMB control number. Application Number 10/804640-Conf. #7762 Filing Date **TRANSMITTAL** March 19, 2004 First Named Inventor **FORM** Matthias WAGNER Art Unit 2883 (to be used for all correspondence after initial filing) **Examiner Name** J. P. Hughes Attorney Docket Number Total Number of Pages in This Submission 0111554.00132US3 ENCLOSURES (Check all that apply) After Allowance Communication Fee Transmittal Form Drawing(s) Appeal Communication to Board of Fee Attached Licensing-related Papers Appeals and Interferences Appeal Communication to TC Amendment/Reply Petition (Appeal Notice, Brief, Reply Brief) Petition to Convert to a After Final Proprietary Information Provisional Application Power of Attorney, Revocation Change of Correspondence Address Affidavits/declaration(s) Status Letter Other Enclosure(s) (please **Extension of Time Request** X Terminal Disclaimer Identify below): - Form PTO SB-08 **Express Abandonment Request** Request for Refund - 93 Non-US Patent References - Return Postcard x Information Disclosure Statement CD, Number of CD(s) Certified Copy of Priority Landscape Table on CD Document(s) Reply to Missing Parts/ Remarks Incomplete Application Reply to Missing Parts under 37 CFR 1.52 or 1.53 SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT Firm Name WIDMER, OUTLER PICKERING HALE AND DORR LLP Signature Printed name Eric L. Prahl

Reg. No.

32,590

Date



Docket No.: 0111554.00132US3

(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Matthias WAGNER et al.

Application No.: 10/804640

Confirmation No.: 7762

Filed: March 19, 2004

Art Unit: 2883

For: TUNABLE AND SWITCHABLE MULTIPLE-

CAVITY THIN-FILM OPTICAL FILTERS

Examiner: J. P. Hughes

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Dear Sir:

Pursuant to the duty of disclosure under 37 C.F.R. §§ 1.56, 1.97 and 1.98, Applicants bring to the attention of the Examiner the documents listed on the attached Form SB/08.

This Information Disclosure Statement is being filed prior to the mailing date of a first Office Action on the merits. No fee is required, however, the Commissioner is authorized to charge any fees due with this filing to Deposit Account No. 08-0219.

Applicants request that the Examiner initial and return a copy of the enclosed Form PTO SB/08 with the next communication.

Dated: February 24, 2006

Respectfully submitted,

Eric L. Prahl

Registration No.: 32,590

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Substitute for form 1449A/B/PTO

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use as many sheets as necessary)

Sheet 1 of 6

	Complete if Known
Application Number	10/804640-Conf. #7762
Filing Date	March 19, 2004
First Named Inventor	Matthias WAGNER
Art Unit	2883
Examiner Name	J. P. Hughes
Attorney Docket Number	0111554.00132US3

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				Application Number	10/804640-Conf. #7762	
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5	STATEMENT	TBY AF	PPLICANT	First Named Inventor	Matthias WAGNER	
				Art Unit	2883	
L	(Use as many	sheets as ne	ecessary)	Examiner Name	J. P. Hughes	
Sheet	2	of	6	Attorney Docket Number	0111554.00132US3	

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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. *CITE NO.: Those application(s) which are marked with an single asterisk (*) next to the Cite No. are not supplied (under 37 CFR 1.98(a)(2)(iii)) because that application was filed after June 30, 2003 or is available in the IFW. ¹ Applicant's unique citation designation number (optional). ³ See Kinds Codes of USPTO Patent Documents at www.uspto.gog or MPEP 901.04. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). * For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. ⁶ Applicant is to place a check mark here if English language Translation is attached.

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INF	FORMATIC	ON DI	SCLOSURE	Filing Date	March 19, 2004	
ST	ATEMEN'	T BY	APPLICANT	First Named Inventor	Matthias WAGNER	
				Art Unit	2883	
	(Use as many	y sheets as	s necessary)	Examiner Name	J. P. Hughes	
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(Use as many sheets as necessary)				Examiner Name	J. P. Hughes	
Sheet	6	of	6	Attomey Docket Number	0111554.00132US3	

CB2	YANG et al., "Amorphous Silicon and SiGe Alloy Solar Cells Deposited by VHF", <i>Mat. Res. Soc. Symp.</i> , Vol. 664, p. A11.3.1, 2001	
CC2	ZHAO et al., "Optomechanical Uncooled Infrared Imaging System: Design, Microfabrication, and Performance", <i>Journal of Microelectromechanical Systems</i> , Vol. 11, No. 2, pp. 136-146, 2002	

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